



1752

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN THE MATTER OF:

NAGAHARA et al

SERIAL NO.: 09/806,852

GROUP: 1752

EXAMINER: LEE, Sin J.

Filed: April 4, 2001

FOR: PHOTORESISTIVE POLYSILAZANE COMPOSITION AND METHOD OF
FORMING PATTERNED POLYSILAZANE

SUPPLEMENTAL AMENDMENT

Assistant Commissioner of Patents
& Trademarks
Washington, DC 20231

SIR:

This is supplemental to the response filed in the United States Patent Office on January 13, 2003 in response to the Office Action dated October 4, 2002 in connection with the above-identified patent application.

Any necessary fees in connection with this matter should be deducted from Deposit Account No. 01-1944.

Please further amend the application as follows:

IN THE CLAIMS

Please amend new claims 23-29 as attached hereto. A copy of new claims 23-29 as amended and a copy of new claims 23-29 showing the amendments is attached hereto.

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